

Electronic Supplementary Information

Solvothermal-induced α -Fe₂O₃/Graphene Nanocomposite with Ultrahigh Capacitance and Excellent Rate Capability for Supercapacitor

Hang Zhang, Qiuming Gao,* Kai Yang, Yanli Tan, Weiqian Tian, Lihua Zhu, Zeyu Li, and Chunxiao Yang

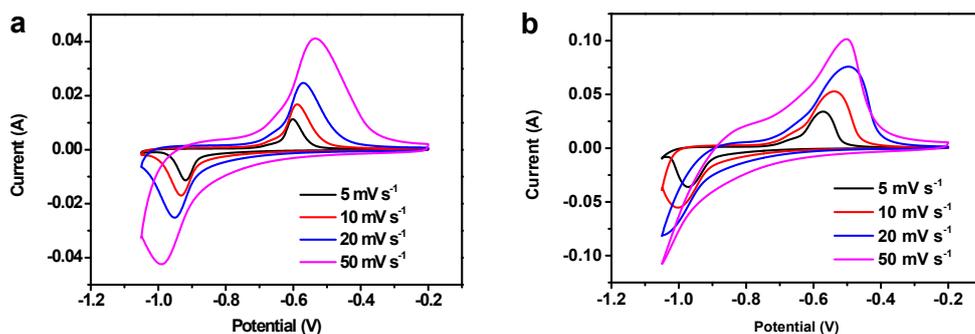


Figure S1. CV curves of the Fe₂O₃/GH-1 (a) and Fe₂O₃/GH-3 (b) composites at different scan rates.

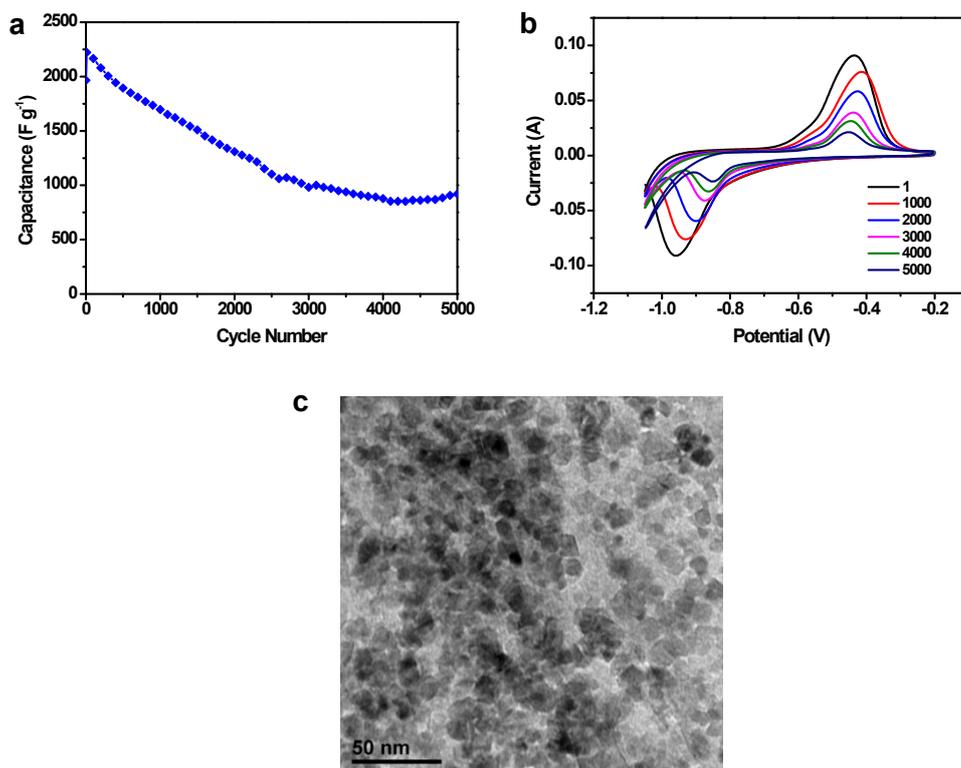


Figure S2. The specific capacitances (a) and the CV curves (b) of Fe₂O₃/GH-2 sample at 20 mV s⁻¹ for 5000 cycles. The capacitance retention was 46.8% (920 F g⁻¹). And TEM image (c) of Fe₂O₃/GH-2 sample after 5000 cycles, showing the partially damaged and aggregated Fe₂O₃ particles.

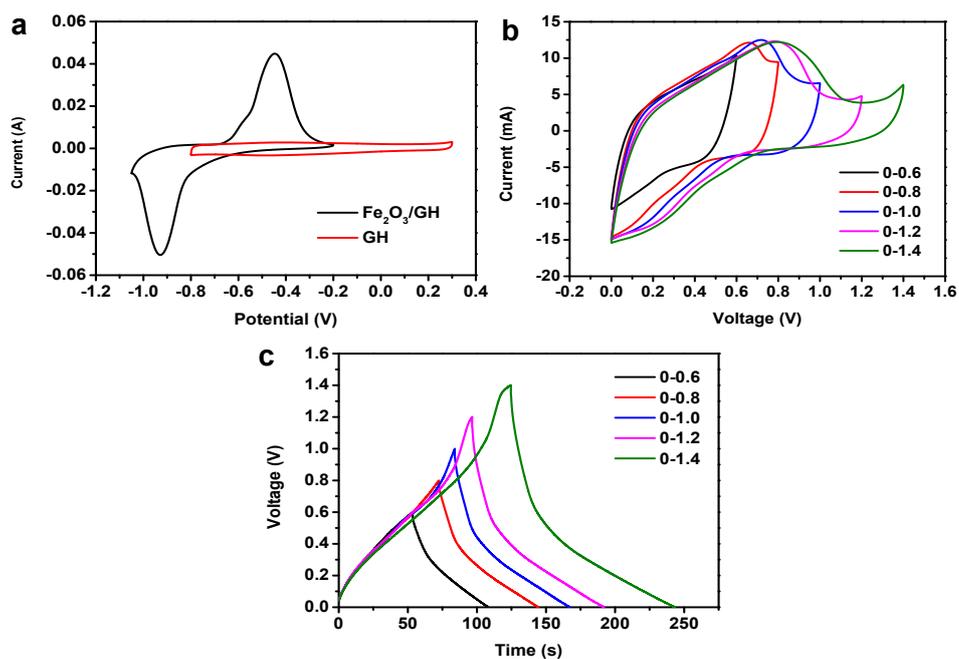


Figure S3. CV curves (a) of the $\text{Fe}_2\text{O}_3/\text{GH}$ -2 composite and GH samples at 20 mV s^{-1} as well as CV curves (b) and galvanostatic charge-discharge curves (c) of the $\text{Fe}_2\text{O}_3/\text{GH}/\text{GH}$ ASCs under different voltage windows.

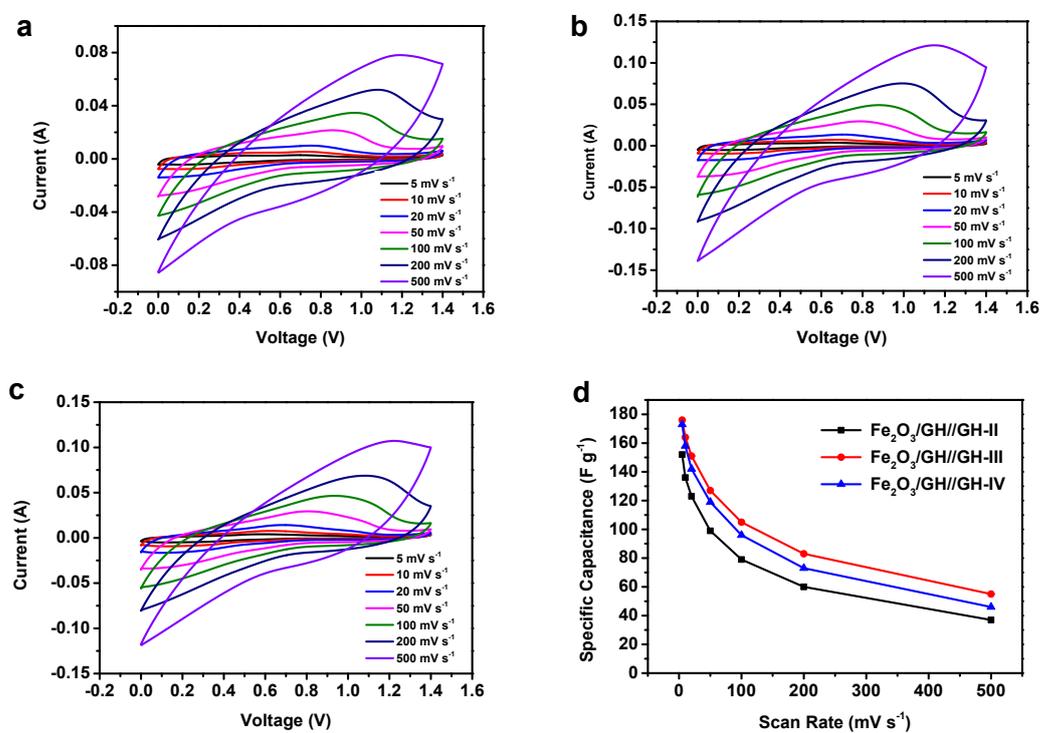


Figure S4. CV curves of the $\text{Fe}_2\text{O}_3/\text{GH}/\text{GH}$ -II (a), $\text{Fe}_2\text{O}_3/\text{GH}/\text{GH}$ -III (b) and $\text{Fe}_2\text{O}_3/\text{GH}/\text{GH}$ -IV (c) ASCs as well as the special capacitance of different ASCs corresponding to different scan rates (d).

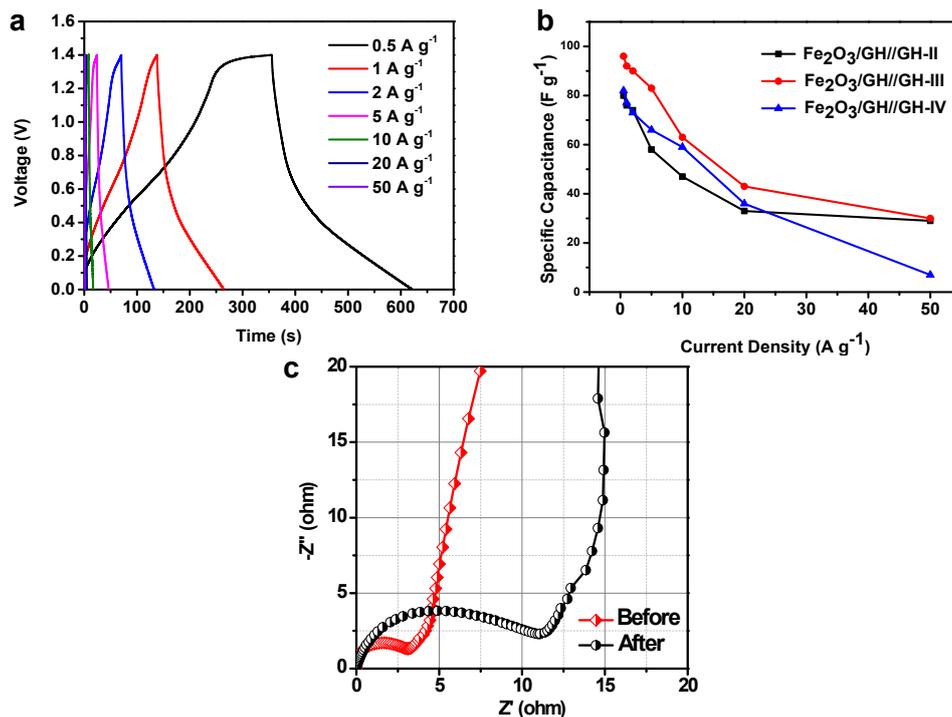


Figure S5. Galvanostatic charge-discharge curves (a) of the $\text{Fe}_2\text{O}_3/\text{GH//GH-III}$ ASC at different current densities (0-1.4 V) and the special capacitance of the $\text{Fe}_2\text{O}_3/\text{GH//GH-III}$ ASC tested at current density of 5 A g^{-1} (b) as well as the EIS analyses (c) of the $\text{Fe}_2\text{O}_3/\text{GH//GH-III}$ ASC before and after 5000 cycles test.

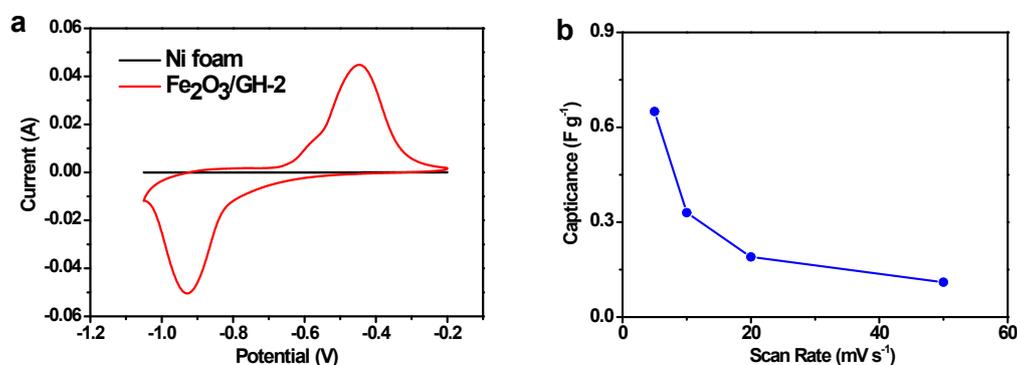


Figure S6. The CV curves (a) of Ni foam loaded with (red) and without (black) active material $\text{Fe}_2\text{O}_3/\text{GH-2}$ at 20 mV s^{-1} as well as the specific capacitance (b) of Ni foam without active material calculated by CV test. The specific capacitance for Ni foam with the same treatment was 0.065 F g^{-1} at 5 mV s^{-1} , while the value was 2310 F g^{-1} for the sample-loaded electrode. Considering the different mass of Ni substrate (about 72 mg) and $\text{Fe}_2\text{O}_3/\text{GH-2}$ sample (about 1 mg), the capacitance values came to 4.7 mF and 2310 mF, respectively. It is obvious that the effect of Ni foam on capacitance is negligible.